

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2056	438/625,592,163,149,151,157.ccor.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/22 09:51
L2	1373	L1 and @ad<"20020920"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/22 09:01
L3	0	438/625,592,163,149,151,157.ccls. and (etch\$3 near5 (conductor conductive metal electrode) and (second adj (conductor conductive metal electrode) near4 (mask hardmask resist) near12 (dry adj etch\$3 RIE (reactive adj ion adj etch\$3) (plasma adj etch\$3))) and dop\$3).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/22 09:55
L4	0	438/625,592,163,149,151,157.ccls. and (etch\$3 near5 (conductor conductive metal electrode) and (second adj (conductor conductive metal electrode) near4 (mask hardmask resist) near12 (dry adj etch\$3 RIE (reactive adj ion adj etch\$3) (plasma adj etch\$3))) and dop\$3).clm.	US-PGPUB	OR	ON	2006/03/22 09:56
L5	0	438/625,592,163,149,151,157.ccls. and (etch\$3 near5 (conductor conductive metal electrode wire wiring) and (second adj (conductor conductive metal electrode wire wiring) near4 (mask hardmask resist) near12 (dry adj etch\$3 RIE (reactive adj ion adj etch\$3) (plasma adj etch\$3))) and dop\$3). clm.	US-PGPUB	OR	ON	2006/03/22 09:56
L6	0	438/625,592,163,149,151,157.ccls. and (etch\$3 near5 (conductor conductive metal electrode wire wiring) and (second adj (conductor conductive metal electrode wire wiring) near8 (mask hardmask resist) near12 (dry adj etch\$3 RIE (reactive adj ion adj etch\$3) (plasma adj etch\$3))) and dop\$3). clm.	US-PGPUB	OR	ON	2006/03/22 09:56

## EAST Search History

S10 5	1	@pn="6905907"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/21 17:05
S10 6	2	"20020009818"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/03/22 09:01